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Low Maintenance

- Sensitive, absolute measurement using Cavity Ring-Down Spectroscopy (CRDS)
- Drift-free, with calibration traceable to the world's leading reference labs
- Low cost of ownership

Multi-Max AMC Monitoring Solution

You can spend a long time looking for Airborne Molecular Contaminants (AMCs) when the catastrophic product performance or yield loss is discovered at your device final test stage; or you can deploy our **Multi-Max**TM **AMC Monitoring Solution** to locate and to monitor these invisible defect generators, commonly found lurking in and around equipment, personnel, wafer carriers, and cleanroom bays.

In today's advanced semiconductor processing, the residual gases, vapors and chemicals emanating from the various materials, accelerated processing operations, and substrate storage and transport have become a critical concern.

The International Technology Roadmap for Semiconductors (ITRS) now highlights AMC contamination as a key technical challenge in achieving and sustaining low defect rates on devices.

With a particular focus on the major contributors to the "chemical contamination" element of AMCs, our Multi-Max AMC Monitoring combines our **T-I Max series CRDS analyzers** that can detect and continuously monitor HF, HCl, and NH₃ with an unprecedented combination of sensitivity, selectivity, and speed of response. Our AMC Monitoring Solution delivers the flexibility, accuracy and reliability you need.

BENEFITS

- Shortest distance of the sample gas flow path (reduced by more than 60% compared to the existing system)
- Minimize the use of contaminants such as fittings and tubing
- Various operation screens are provided for user convenience and can be programmed
- Minimization of contamination inside the sampler (automatic purge function when the system is stopped: CDA/PN2 required)
- Added reference function to check contamination
- Minimize preventive maintenance points (minimize internal inspections by making blocks)



A Flexible Solution for AMC Monitoring

Surveying different micro-environments in a fab is now fast and easy with our safe, flexible, and easy to use Multi-Max AMC Monitoring Solution.

Our solution can be quipped with **any combination** of our **T-I Max CRDS analyzers** to monitor simultaneously and in real-time for the most critical contaminants in cleanroom air: NH₃, HCl, and HF (other analytes available as well). All our analyzers come with a compact, low-power, fanless vacuum pump optimized for cleanroom operation.



Multi-Max AMC Monitoring Solution



Our **T-I Max series CRDS analyzers** are robust, designed free of moving parts, resulting in a high mean time between failures (MTBF) and a very low cost of ownership (COO) delivering unprecedented performance including:

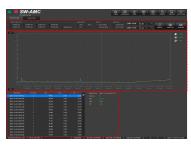
- Sensitive, absolute measurement technique, using Cavity Ring-Down Spectroscopy (CRDS)
- Parts-per-trillion detection limits
- Drift-free, with calibration traceable to the world's leading reference labs
- Lowest cost of ownership and maintenance
- High specificity no interference
- No periodic sensor replacement/maintenance
- Unprecedented speed of response
- Wide dynamic range

User-Friendly Interface

The Multi-Max AMC Monitoring Solution user interface is easy to use.



- 1 Basic Status
 - Open Valve#
 - Maintenance Status and PLC/UPS Communication status
- ② Analyzer Data Display and Control
 - Sequence Start and Stop
 - Sequence Status
 - Port status, Time and Data
 - Data Graph in each Port
- 3 Temperature and Flow
 - Pump Temperature
 - Analyzer Flow and Bypass Flow Display
- 4 Analyzer Status and Data
 - Data and Graph Display
 - Calibration Data and Concentration Display
- System Log
 - Sampler Status and Sequence





Next-Generation AMC Monitoring Solution

Specifications

Performance			
Operating range	See table below		
Detection limit (LDL, 3σ@100s)	See table below		
Precision (1σ@100s, greater of)	± 0.5% or 1/3 of LDL		
Accuracy at span	± 4% of reading		
Accuracy at zero	See table below		
Speed of response @ 20ppb	See table below		
(T10/90 + T90/10)			
Environmental conditions	10°C to 40°C		
	10% to 90% RH (non-condensing)		
Sample conditions	17°C to 23°C		
	35% to 55% RH		
Storage temperature	-10°C to 50°C		

Multi-Max AMC	1,851(H) x 630(W) x 897(D) mm
Weight	
T-I Max analyzer Multi-Max AMC (both excl. vacuum pump)	15 kg 380 kg
Electrical and Interfaces	
Electrical Total Power Consumption Running Power Consumption	220VAC, 50/60 Hz 1255 Watts 904 Watts
User interfaces	LCD touchscreen
	10/100 Base-T Ethernet

USB, RS-232, RS-485 Modbus TCP (optional)

Internal or external flash drive

HxWxD

Gas Handling System and Conditions*				
Wetted materials	Optimized for ppt-level AMCs			
	and fast speed of response			
Gas connections	1/4" PFA Swagelok® inlet & outlet			
Inlet pressure	Atmospheric pressure†			
Outlet pressure	Vacuum (<10 Torr)			
Flow rate	~3 slpm@1 atm pressure (NH ₃)			
	~2 slpm@1 atm pressure (HF, HCl)			
Sample gases	Cleanroom air, CDA or N ₂			
Gas temperature	Up to 60°C			

Performance in cleanroom air:	Range	LDL (3σ@100s)	Accuracy at zero	Speed of Response (T10/90+T90/10)
T-I Max HF	0 – 1 ppm	20 ppt	± 20 ppt	< 3 minutes @ 20 ppb
T-I Max HCI	0 – 4 ppm	100 ppt	± 200 ppt	< 30 seconds @ 20 ppb
T-I Max NH₃	0 – 40 ppm	300 ppt	± 300 ppt	< 3 minutes @ 20 ppb

Data storage

Dimensions

Contact us for additional analytes.

U.S. Patent # 7,277,177

^{*}Vacuum source with >2 slpm @ 10 Torr required

[†]Contact us for details about operating the analyzer at elevated inlet pressure.

Quality & Performance · Regulatory Compliance · Peace of Mind



Analyzer Performance Verification Program

- · Simple, in-situ verification process
- Maximum analyzer uptime
- · Cost-effective compliance
- No specialty calibration gas
- Fast completion





Get your analyzer verified every year!

You can expect thee highest level of support with our Multi-Max AMC Monitoring Solution. Our CRDS Analyzer Performance Verification Program is a valuable annual health check that helps your analyzers perform within specifications, function at high factory standards and meet the requirements of regulatory agencies.

Your written certificate can be shared with auditors and leadership teams for compliance and quality management.

- Low cost and easy remote verification process, with no need to return the analyzer to the factory
- Annual verification ensures that your analyzer continues to meet its original specifications
- Up-to-date Verification Certificate to comply with your
- QA/QC standards

THE VERIFICATION PROGRAM IS EASY & CONVENIENT

Our Gas Laboratory and Final Testing Facility in Horsham, PA is equipped with state-of-the-art, NIST-certified calibration systems to perform analyzer test, calibration, and qualifications. Our deep knowledge, expertise and experience is well-known throughout the industry as a leader in gas analysis.



PREMIUM INSIGHTS – GAIN REAL-TIME INSIGHT INTO YOUR PROCESS

Process Insights' products and solutions deliver innovative and differentiated analysis and measurement solutions and technologies that add high value to our customers and protect the environment.

Our commitment is to deliver smart and affordable innovation that optimizes process, improves safety, and transforms our world.

CENTERS OF EXCELLENCE | PROVIDING PROVEN SOLUTIONS

Process Insights is committed to solving our customers' most complex analytical, process, and measurement challenges everyday.

Process Insights – The Americas

4140 World Houston Parkway Suite 180, Houston, TX 77032, USA +1 713 947 9591

Process Insights - EMEA

ATRICOM, Lyoner Strasse 15, 60528 Frankfurt, Germany +49 69 20436910

Process Insights - APAC

Wujiang Economic and Technology, Development Zone, No. 258 Yi He Road, 215200 Suzhou Jiangsu Province, China +86 400 086 0106

For a complete range of products, applications, systems, and service options, please contact us at: info@process-insights.com

For a complete list of sales & manufacturing sites, please visit: https://www.process-insights.com/about-us/locations

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